

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of) Confirmation No. 4499
Inventor(s): Li Yao et al.)
1 1 1 10/600 040) Group Art Unit: 1765
Appln. No.: 10/689,043) Examiner: ALANKO A. K.
Filed: October 21, 2003) Liaminici. ALANKO A. K.
)
For: Abrasive-Free chemical mechanical polishing) .
COMPOSITION AND POLISHING PROCESS CONTAINING SAME) .

RESPONSE UNDER 37 C.F.R. §1.114

U.S. Patent and Trademark Office Randolph Building 401 Dulany Street Alexandria, Virginia 22314 MAIL STOP – AMENDMENT

Sir:

In response to the final Office Action mailed on April 20, 2007 and in accordance with 37 CFR §1.114, this Amendment and Response is submitted for consideration. The instant amendment is accompanied by a Request for Continued Examination (RCE):

Amendments to the claims begin on page 2 of this paper.

Remarks begin on page 6 of this paper.